## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re:

Margaret B. Stern, et al.

Serial No:

09/725,354

2873 Group:

Filed:

November 29, 2000

Examiner: Hasan, Mohammed A.

For:

Alignment Mark System For Mass

Transport Processes

Date: January 28, 2003

Patent Application

## **RESPONSE UNDER RULE 111**

## **Assistant Commission for Patents**

Washington, D.C. 20231

Sir:

In response to the pending Office Action, mailed August 28, 2002 (Paper No. 7), Applicants hereby request reconsideration in view of the following remarks. FAX RECEIVED

JAN 2 8 2005

## Remarks:

Claims 1-26 are pending in this application.

**TECHNOLOGY CENTER 2800** 

Applicants are grateful for the indication of allowable subject matter. As outlined below, however, applicants believe that all of the claims are allowable over the applied references.

Claims 1 and 14 were rejected as being anticipated by the Dirksen patent ('650). Claims 2, 3, 9-13, 15, 16, and 22-26 were rejected as being unpatentable over the Dirksen patent in view of the Liau patent ('622). These rejections are respectfully traversed for the following reasons.

The invention of claim I, for example, features a substrate that has been subjected to a mass transport process and a lens alignment structure formed on the substrate that yields a light pattern when the substrate or a plane near the substrate is imaged. Claim 14 also features a lens alignment structure.